# **Special Issue**

### Emerging Trends in Embedded Systems and Applications for Intelligent Process Control

### Message from the Guest Editors

For this Special Issue, authors are encouraged to submit their original research in any of the following or related areas:

- Intelligent control systems
- Embedded intelligence and machine learning
- Software/hardware co-design and optimization
- Energy efficient architecture design
- Micro- and nano-systems
- Run-time power optimization
- Wireless communication and tracking
- Optimization algorithms

### Guest Editors

Dr. Charalampos S. Kouzinopoulos

Information Technologies Institute (ITI)/Centre of Research and Technology Hellas, Thessaloniki, Greece

#### Prof. Dr. Konstantinos Margaritis

Department of Applied Informatics, Unversity of Macedonia, 156 Egnatia Str., 54636 Thessaloniki, Greece

### Deadline for manuscript submissions

closed (28 February 2024)



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Prof. Dr. Giancarlo Cravotto

Department of Drug Science and Technology, University of Turin, Via P. Giuria 9, 10125 Turin, Italy

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